



Microcomb Fabrication Update

For Constellation-X Facility Science Team Meeting



Space Nanotechnology Laboratory

Yanxia Sun, Ralf Heilmann, Carl Chen, Craig Forest, Mark Schattenburg

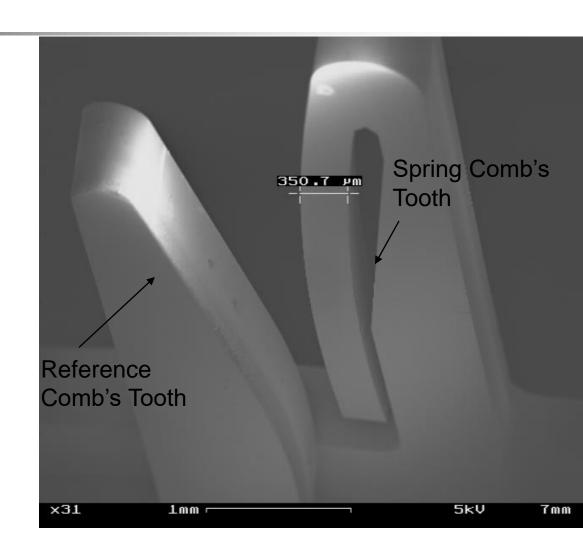
September 18, 2002



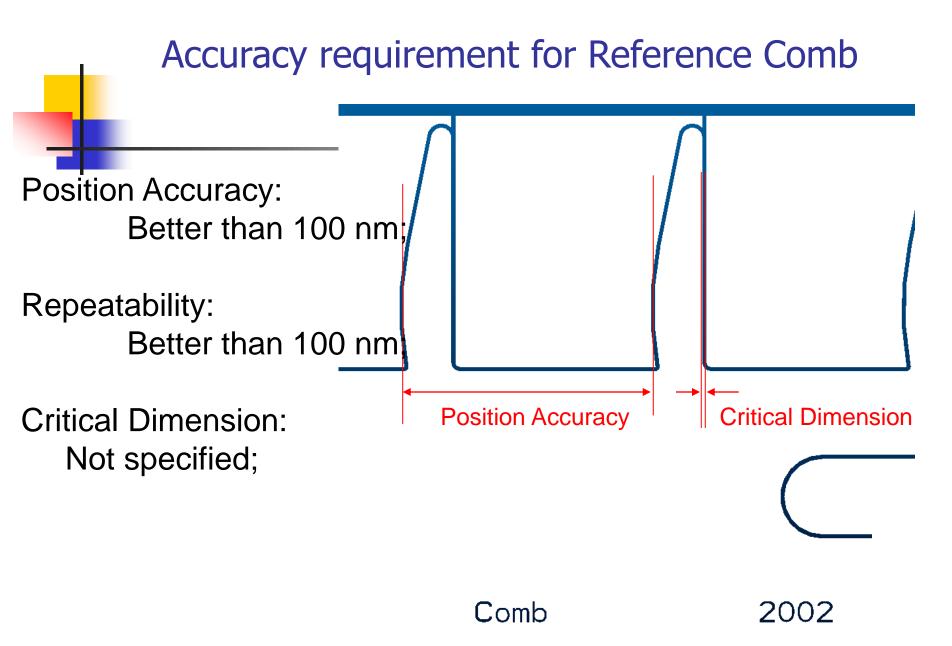


Microcomb for Precision X-ray Foils Assembly

- Accuracy requirement for reference comb;
- Previous fabrication process and problem;
- •New 2-mask fabrication process.
- Future work: "Tall-teeth" microcomb for SXT









Previous Fabrication Process

(a) DSP silicon wafer, Thermal diffusion 2 μm SiO₂;



(b) Contact print thick PR;



(c) Etch SiO₂;



(d) DIRE with quartz handle-wafer, etch through;



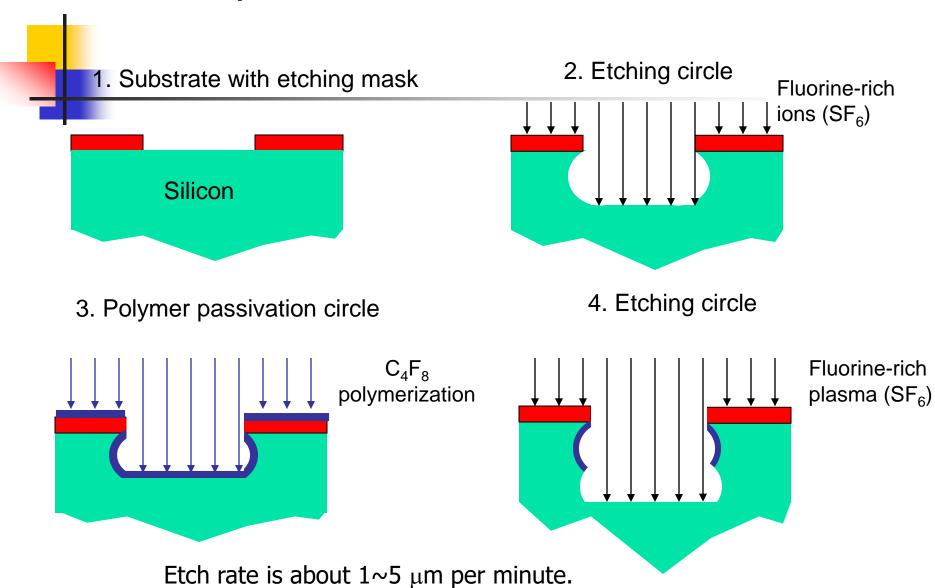
(e) Strip PR, BOE, Extract finished microcomb;





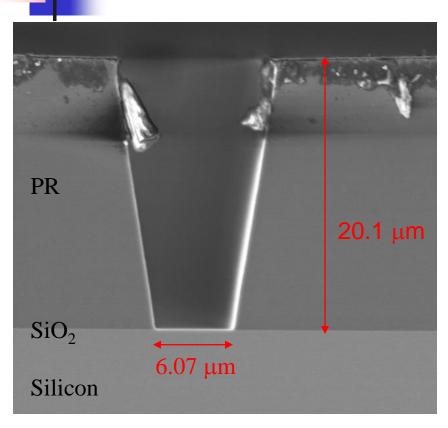
•200 nm accuracy has been achieved based on 4 inch wafer process.

Deep Reactive Ion Etch for Silicon

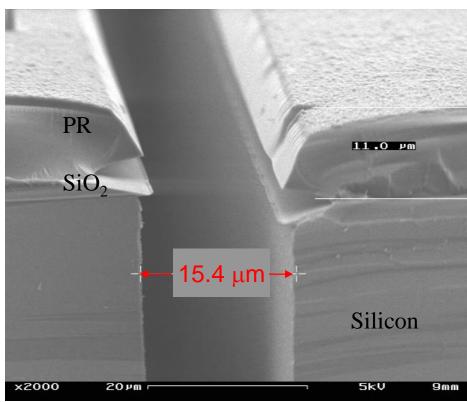


Long-term Deep Reactive Ion Etch for Silicon

Thick Photoresist and oxide layer are required, which will introduce big CD loss and low repeatability.



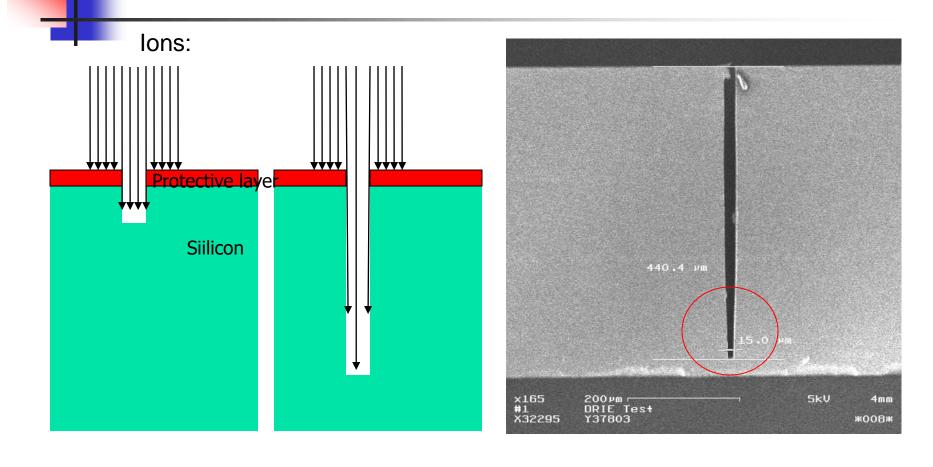
Thick Photoresist Profile



After 4.5 hour Deep Reactive Ion Etch for Silicon

Long-term Deep Reactive Ion Etch for Silicon

•The effect from angular ion distribution is amplified when etching deeper.



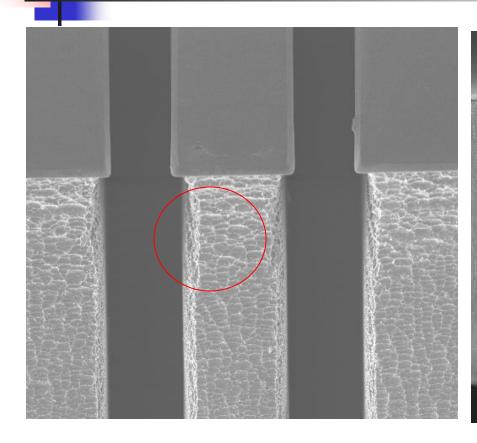


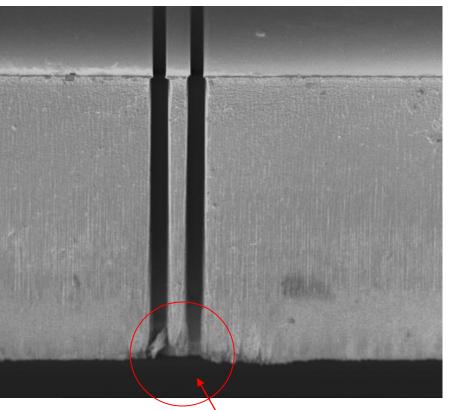


Long-term Deep Reactive Ion Etch for Silicon

Rough sidewall surface if overetching;

Backside erosion when etching through;





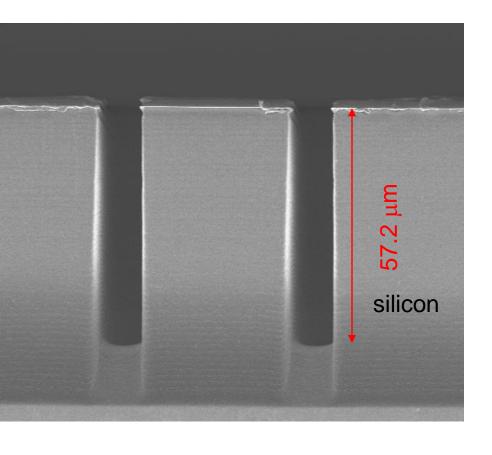
Backside erosion

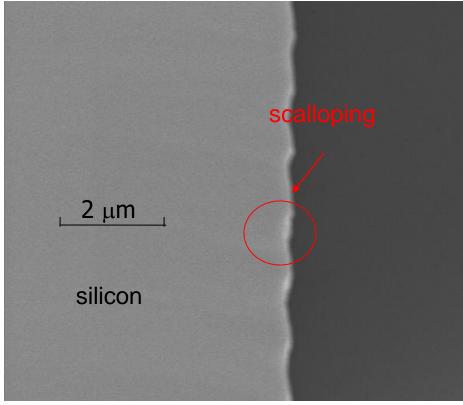






20 minutes Deep Reactive Ion Etch for Silicon

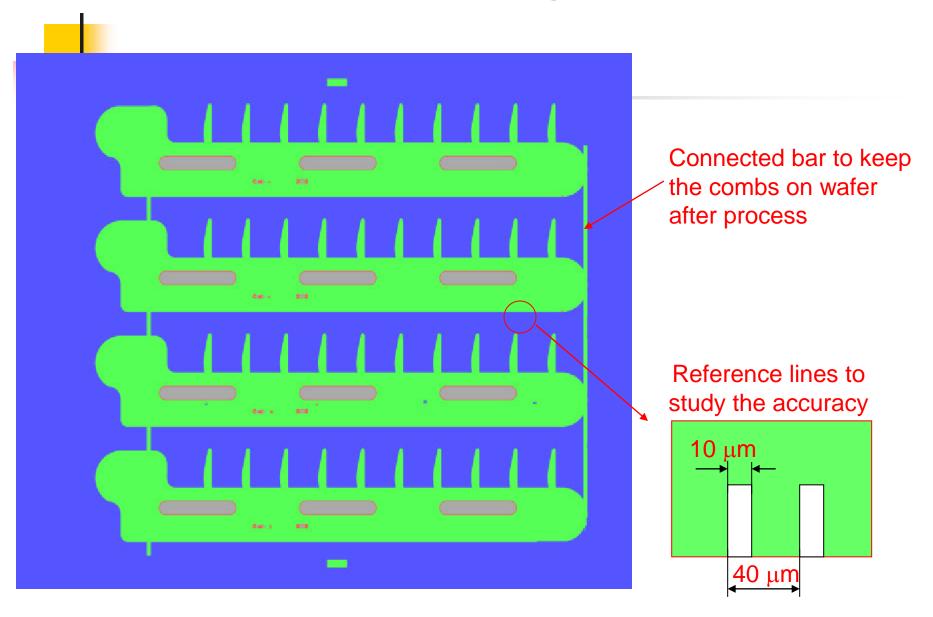








Mask Design







Two-mask Process



(a) DSP silicon wafer, Thermal diffusion 0.5~1 μm SiO₂;



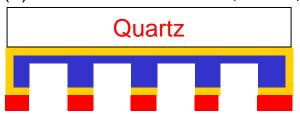
(b) Lithography for backside etch;



(c) Backside silicon dioxide etch;



(d) Backside silicon etch, DRIE;



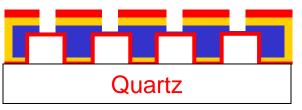
(e) Lithography for front side etch;



(f) Front side silicon dioxide etch;



(g) Front side silicon etch, DRIE with backside protection with photoresist



(h) Clean wafer, get comb out;





"Tall Teeth" Micro-comb

- 1. 10mm long reference tooth to avoid rough edge of the mirror;
- EDM-cut metal strong-back bonded with silicon microcomb to stiffen reference tooth;

